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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/606,182	06/26/2003	Tsutomu Hashizume	Q76316	1591
7590 12/15/2004			EXAMINER	
SUGHRUE, MION, ZINN, MACPEAK & SEAS			FEGGINS, KRISTAL J	
2100 Pennsylvania Avenue, N.W. Washington, DC 20037			ART UNIT	PAPER NUMBER
wasiington, 2	20037		2861	

Please find below and/or attached an Office communication concerning this application or proceeding.

		<i>X</i>			
	Application No.	Applicant(s)			
	10/606,182	HASHIZUME ET AL.			
Office Action Summary	Examiner	Art Unit			
	K. Feggins	2861			
The MAILING DATE of this communication Period for Reply	on appears on the cover sheet w	ith the correspondence address			
A SHORTENED STATUTORY PERIOD FOR F THE MAILING DATE OF THIS COMMUNICAT - Extensions of time may be available under the provisions of 37 of after SIX (6) MONTHS from the mailing date of this communicat - If the period for reply specified above is less than thirty (30) days - If NO period for reply is specified above, the maximum statutory - Failure to reply within the set or extended period for reply will, by Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	TION. CFR 1.136(a). In no event, however, may a sion. s, a reply within the statutory minimum of thir period will apply and will expire SIX (6) MON y statute, cause the application to become Al	reply be timely filed ty (30) days will be considered timely. ITHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).			
Status					
 1) Responsive to communication(s) filed on 2a) This action is FINAL. 2b) Since this application is in condition for a closed in accordance with the practice un 	This action is non-final. Ilowance except for formal mat	•			
Disposition of Claims					
4) ☐ Claim(s) 21-33 is/are pending in the apple 4a) Of the above claim(s) is/are with 5) ☐ Claim(s) is/are allowed. 6) ☒ Claim(s) 21-33 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction Application Papers 9) ☐ The specification is objected to by the Ex	thdrawn from consideration and/or election requirement.				
·_	☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.				
Applicant may not request that any objection	.,				
Replacement drawing sheet(s) including the call to by the call the	·				
Priority under 35 U.S.C. § 119					
12) △ Acknowledgment is made of a claim for for a) △ All b) ☐ Some * c) ☐ None of: 1. ☐ Certified copies of the priority document of the priority document of the priority document of the copies of the certified copies of the application from the International Experience of the attached detailed Office action for the certified copies of the application from the International Experience of the attached detailed Office action for the certified copies of the attached detailed Office action for the certified copies of the certified copies of the priority document of the certified copies of the c	uments have been received. uments have been received in A e priority documents have beer Bureau (PCT Rule 17.2(a)).	Application No. <u>08/788,959</u> . received in this National Stage			
Attachment(s) 1) Motice of References Cited (PTO-892)	A) 🗆 Indeed Services	Summary (PTO-413)			
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-93) Information Disclosure Statement(s) (PTO-1449 or PTO/Paper No(s)/Mail Date 6/26/2003. 	48) Paper No(s)/Mail Date nformal Patent Application (PTO-152)			

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DETAILED ACTION

Claim Rejections - 35 USC § 102

- 1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:
 - (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 21-33 are rejected under 35 U.S.C. 102(e) as being anticipated by Miyashita et al. (US 6140746).

Miyashita et al. disclose the following claimed limitations:

- * regarding claims 21, 25 & 30 an ink jet recording head formed by a method and a method of manufacturing an ink jet recording head (Abstract, fig 4);
- * forming a first/lower/ electrode layer/23/ on a diaphragm/22/ (col 10, lines 27-34, fig 4);
- * forming a piezoelectric layer24/ on the first/lower/ electrode layer/23/ (col 10, lines 27-34, fig 4);
- * forming a second/upper/ electrode layer/25/ on the piezoelectric layer/24/ (col 10, lines 27-34, fig 4);
- * etching completely through the second/upper/ electrode layer/25/, the piezoelectric layer/24/, and the first/lower/ electrode layer/23/ so that a portion/the ends/ of the diaphragm/22/ is exposed (col 11, lines 56-66, figs 3 & 4).

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* regarding claims 22, 26 & 31, wherein the diaphragm/22/ is attached to a substrate/21/(col 10, lines fig 4);

- * regarding claim 29, wherein only a single mask material is used to pattern the second electrode layer, the piezoelectric layer, and the first electrode layer during the etching step (col 11, lines 20-40, 56-67, col 12, lines 1-9, fig 3).
- * further regarding claim 30, etching completely through at least the second electrode layer and the piezoelectric layer so that a portion of the diaphragm is exposed (col 11, lines 20-40, 56-67, col 12, lines 1-9, fig 3).

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 23, 24, 27, 28, 32, 33 are rejected under 35 U.S.C. 103(a) as being unpatentable over Miyashita et al. (US 6140746) in view of Miyata et al. (US 5,754,205). Miyashita et al. disclose all of the claimed limitations except for the following:
- * regarding claims 23, 27 & 32, wherein a nozzle plate is attached to the substrate.

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* regarding claims 24, 28 & 33, wherein the nozzle plate is formed with a nozzle orifice.

Miyata et al. disclose the following claimed limitations:

* regarding claims 23, 27 & 32, wherein a nozzle plate/53/ is attached to the substrate (col 7, lines 39-42, fig 3b) for the purpose of providing a plurality of nozzle openings fixed to one face of the substrate.

* regarding claims 24, 28 & 33, wherein the nozzle plate/53/ is formed with a nozzle orifice/52/ (col 7, lines 39-42, fig 3b) for the purpose of ejecting ink drops through the nozzle opening.

It would have been obvious at the time of the invention was made to a person having ordinary skill in the art to utilize a nozzle plate is attached to the substrate; and a nozzle plate that is formed with a nozzle orifice, taught by Miyata et al. into Miyashita et al. for the purposes of providing a plurality of nozzle openings fixed to one face of the substrate and ejecting ink drops through the nozzle opening.

Conclusion

5. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Hasegawa et al. disclose a liquid jet head having a silicon substrate, a piezoelectric device, upper and lower electrodes and a piezoelectric film.

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Communication With The USPTO

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to K. Feggins whose telephone number is 571-272-2254. The examiner can normally be reached on M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Stephen Meier can be reached on 571-272-2149. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Primary Examiner

December 10, 2004